

# Synthesis, Structure, Magnetic and Electric Transport Properties of W<sub>0.5</sub>Si<sub>0.5</sub>Te<sub>1.95</sub>

## PAWAN K. SHARMA<sup>1</sup> AND INDU B. SHARMA<sup>2</sup>

<sup>1</sup>Govt. Degree College Khour, Jammu, 181203, India. <sup>2</sup>ISCAS, Institute of Solid State and Material Science, Jammu University Campus, Jammu. <sup>1</sup>e-mail of corresponding author: drpksharma59@gmail.com

#### Abstract

A new phase with the composition  $W_{0.5}Si_{0.5}Te_{1.95}$ has been synthesised by the standard ceramic method.X-ray diffraction studiesshow that the phase crystallizes inorthorhombic unit cell (a=21.093Å, b=8.921Å and c=7.252Å).The molar magnetic susceptibility measurements as a function of temperature suggest that the phase is diamagnetic and magnetic susceptibility is temperature independent.The electrical resistivity measurements as a function of temperature suggest that the phase is semi-conductor in nature in the temperature range 300K-500K and the conduction occurs via thermally activated mechanism.The thermal analysis suggests that the phase remains almost stable upto 873K, although there is minor mass gain above 723 K.

Keywords: Mixed binary dichalcogenides, XRD, electrical resistivity, TG-DTA.

#### Introduction:

Binary dichalcogenides of numerous elements with composition  $MX_2$  and their mixed analogues  $M_{1-x}M'X_2$  (M and M'are different transition elements; X=S, Se or Te) are known in the literature [1, 2]. Manydichalcogenides with reduced content of X are also known [3, 4]. It has been reported that structure and physical properties substantially vary with change in composition [1, 2, 3, 4]. It was thoughtinteresting to prepare mixed chalcogenides with composition  $M_{0.5}M'_{0.5}X_2$  study of their crystal structure& follow their physical properties as function of temperature.

In the present study, synthesis of a new phase with the composition  $W_{0.5}Si_{0.5}Te_{1.95}has$  been reported. Its crystal structure has been determined from the powder X-ray diffraction data. Magnetic and electric transport properties have been studied in the temperature range 80K-300K and 300K-500K respectively. The phase has been analysed for thermogravimeteric analysis (TGA) and differential thermogravimeteric analysis (DTGA).

#### Experiment

## **Synthesis**

Aldrich makeTungsten (W)Silicon (Si) and Tellurium (Te) elements (purity 99.9%) havebeen used for synthesis of the new phase. The constituent elements weighed corresponding to the stoichiometry  $W_{0.5}Si_{0.5}Te_{1.95}$ , were mixed and homogenised by grinding in cyclohexane. The dried and homogenised mixture, pressed into pellets in hydraulicpress was placed in quartz tube and evacuated to ~10<sup>-5</sup> Torr, vacuum sealed and was heat- treated at 1048K for 72 hours. The mixture during the heat treatment was



subjected to a number of intermediate grindings, pelletizing and sealing undersame conditions for the completion of the reaction. The final product was pulverised to fine powder for further investigations [5, 6, 7].

## Elemental Analysis

The phase was further analysed by atomic absorption spectrophotometry, which is one of the most prevalent methods for the trace element analysis [8, 9, 10]. The results of chemical elemental analysis [11, 12] and the atomic absorption spectrophotometry are in good agreement. The data are given in Table 1.

**Table 1:** Analytical data of the phase ( $W_{0.5}Si_{0.5}Te_{1.95}$ ). The theoretical value is given parenthesis.

| Phase                      | Wo            | Si          | Te            |
|----------------------------|---------------|-------------|---------------|
| $W_{0.5}Si_{0.5}Te_{1.95}$ | 25.21 (25.45) | 3.69 (3.88) | 68.89 (70.65) |

## Analysis (%)

## X-ray Diffraction studies

Room temperature powder X-ray diffraction data of the product were recorded on a Stoe-powder diffraction system and a Philips diffractometer at a scanning speed of 1deg./minute in the  $2^{6}$  range usingCuKa and FeKa radiations[13, 14 and 15].The X- ray diffraction data are given in the Table 2, while the X-ray pattern, intensity, versus  $2^{6}$  is drawn in the figure 1.



Figure 1:X-ray Diffraction pattern of W<sub>0.5</sub>Si<sub>0.5</sub>Te<sub>1.95</sub>

## Magnetic Susceptibility Measurement

Magnetic susceptibility of the powdered phase was recorded in a Faraday balance provided with Polytronic Faraday-type electromagnet and a Mettler microbalance. Specially fabricated Dewar flask of the size which could be adjusted within polegaps of electromagnet was used for keeping liquid nitrogen, which surrounded the phase crucible [16, 17]. The phase was held hanging in the inner tube of the Dewar



flask with a fine thread. Magnetic susceptibility in the temperature range 77K-300K could be measured by this arrangement.

#### Electrical Resistance study

Electrical Resistivity of thin pellet of the phase as a function of temperature in a continues flow of nitrogen was recorded by four probe method in a four probe cell, using Keithley programmable constant current supply source model 224 and nanovoltmetermodel181 for the purpose of current source and voltage measurement respectively [18,19]. The bottom surface of the pellet was kept non-conducting. The data of specific resistance ( $\rho$ ) as a function of temperature are given in Table 4, while the log  $\rho$  versus 1/T data are plotted in the figure 2.



Figure 2:Log versus 1/T plot of  $W_{0.5}Si_{0.5}Te_{1.95}$ 

## Thermal Analysis

The phase has been thermally analyzed for thermogravimeteric (TG) and differential thermal analysis (DTA) by Rigaku thermalAnalysis System 8150, provided with a microprocessor, in the temperature range 300K-873K at the heating rate of 10 deg./min in continuous flow of nitrogen [20, 21]. The TG and DTA plot is given in figure 3.

## **Results and Discussion**

#### **Crystal Structure**

The unit cell parameters of the phase were calculated from X-ray diffraction data (Table 2). The indexing of the data shows that it crystallises in orthorhombic unit cell (a=21.093Å, b=8.921Å and



c=7.252Å). In order to determine the crystal structure, the theoreticalX-ray diffractiondata were generated by Treor (Noel *et al.*, 1996) and Lazy-Pulverix analysis (Yvon *et al.*, 1977). The  $d_{cal}$  values computed from data are in good agreement with the experimental interplanar distances. The data along with the assigned **h** k l values are given in the Table 2



Figure 3: TG-DTA Curves of W<sub>0.5</sub>Si<sub>0.5</sub>Te<sub>1.95</sub>

| h          | k | l       | d <sub>obs</sub> (Å) | d <sub>cal</sub> (Å) | I <sub>obs</sub> |
|------------|---|---------|----------------------|----------------------|------------------|
| 0          | 0 | 1       | 7.243                | 7.258                | 49.2             |
| 2          | 2 | 0       | 4.115                | 4.111                | 3.8              |
| 6          | 0 | 1       | 3.163                | 3.165                | 8.1              |
| 0          | 2 | 2       | 2.814                | 2.816                | 6.6              |
| 6          | 2 | 1       | 2.576                | 2.582                | 8.1              |
| 7          | 2 | 1       | 2.362                | 2.362                | 11.6             |
| 2          | 3 | 2       | 2.247                | 2.248                | 3.5              |
| 7          | 3 | 0       | 2.117                | 2.118                | 100.0            |
| 5          | 0 | 3       | 2.098                | 2.099                | 3.0              |
| 8          | 1 | 2       | 2.072                | 2.075                | 2.3              |
| 6          | 3 | 2       | 1.926                | 1.925                | 2.8              |
| 1          | 4 | 2       | 1.892                | 1.893                | 2.3              |
| 4          | 4 | 3       | 1.766                | 1.768                | 4.9              |
| a= 21.093Å | b | =8.921Å | c=7.252Å             | 1                    | 1                |

Table 2: Powder X-ray Diffraction Data of W<sub>0.5</sub>Si<sub>0.5</sub>Te<sub>1.95</sub>



| Temperature (K) | Specific resistancep<br>(ohm cm) |  |
|-----------------|----------------------------------|--|
| 446             | 0.100                            |  |
| 442             | 0.103                            |  |
| 437             | 0.105                            |  |
| 432             | 0.108                            |  |
| 427             | 0.110                            |  |
| 422             | 0.112                            |  |
| 417             | 0.114                            |  |
| 412             | 0.117                            |  |
| 407             | 0.119                            |  |
| 403             | 0.122                            |  |
| 398             | 0.124                            |  |
| 393             | 0.126                            |  |
| 388             | 0.128                            |  |
| 383             | 0.130                            |  |
| 379             | 0.131                            |  |
| 374             | 0.133                            |  |
| 369             | 0.136                            |  |
| 364             | 0.137                            |  |
| 360             | 0.138                            |  |
| 355             | 0.141                            |  |
| 350             | 0.143                            |  |
| 345             | 0.145                            |  |
| 340             | 0.148                            |  |
| 335             | 0.151                            |  |
| 330             | 0.154                            |  |
| 325             | 0.158                            |  |
| 320             | 0.162                            |  |
| 315             | 0.166                            |  |
| 310             | 0.170                            |  |
| 305             | 0.174                            |  |

**Table 3:** Specific resistance (log  $\rho$ ) of W<sub>0.5</sub>Si<sub>0.5</sub>Te<sub>1.95</sub>as function of temperature (K).

## Magnetic susceptibility studies

The molar magnetic susceptibility measurements as a function of temperature suggest that the phase is diamagnetic and magnetic susceptibility is temperature independent.

## **Electric Transport Properties**

The electrical resistivity of the phase ( $W_{0.5}Si_{0.5}Te_{1.95}$ ), as function of temperature, is plotted in figure 2.There is a break in the slope of log  $\rho$  versus 1/T plot at around 407 K. The temperature co-efficient of resistivity in both the regions remains negative. The negative temperature co-efficient of resistivity and the values of the specific resistance (Table.3) suggest that the phase is semi-conductor in nature and the electrical conduction occurs via thermal activated mechanism.



### Thermal Analysis:

The thermogravimeteric analysis (TGA) of  $W_{0.5}Si_{0.5}Te_{1.95}fig$ . 3 suggest that the phase remains almost stable up to 873 K, although there is minor mass gain above 723 K. The differential thermal analysis (DTA) curve of this phase shows similar thermal stability up to 719 K, beyond this temperature there is a sharp endothermic peak with peak temperature at 725.7 K.

Table 4: Magnetic and Electric Transport Parameters of (W<sub>0.5</sub>Si<sub>0.5</sub>Te<sub>1.95</sub>) phase.

| Phase   | μ <sub>eff</sub> ( <b>B.M</b> ) | µ <sub>theo</sub> (B.M) | E <sub>a</sub> (eV)                       |
|---|---------------------------------|-------------------------|---|
| W <sub>0.5</sub> Si <sub>0.5</sub> Te <sub>1.95</sub> | Diamagnetic                     | -                       | 0.04<br>(305-393 K)<br>0.07<br>(417-446K) |

#### Conclusion

A new phase with the composition  $W_{0.5}Si_{0.5}Te_{1.95}has$  been synthesised by thestandard ceramic method. On the basis of Lazy-Pulverix analysis of the X-ray diffraction data it is concluded that the phase crystallises in orthorhombic unit cell. The molar magnetic susceptibility measurements as a function of temperature suggest that the phase is diamagnetic and magnetic susceptibility is temperature independent. The study of electrical resistivity in the temperature range 300K-500K shows that the compound is an electrical semi-conductor and conduction occurs via thermal activated mechanism. The thermal analysis suggests that the phase remains almost stable upto 873K, although there is minor mass gain above 723 K.

#### Acknowledgements

Thanks are due to the UGC, New Delhi for financial support, University of Delhi for thermal analysis, IIT Bombay for XRD studies and Department of Chemistry, University of Jammu, Jammu for providing requisite facilities.

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